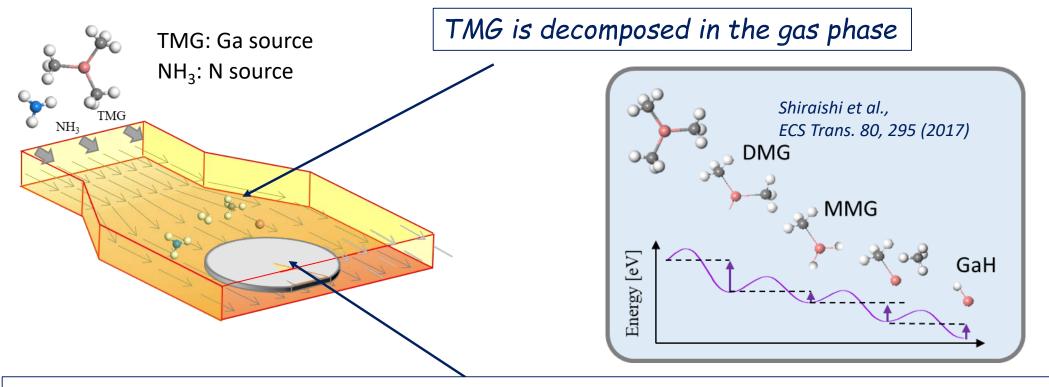
MetalOrganic Vapor Phase Epitaxy (MOVPE) of GaN



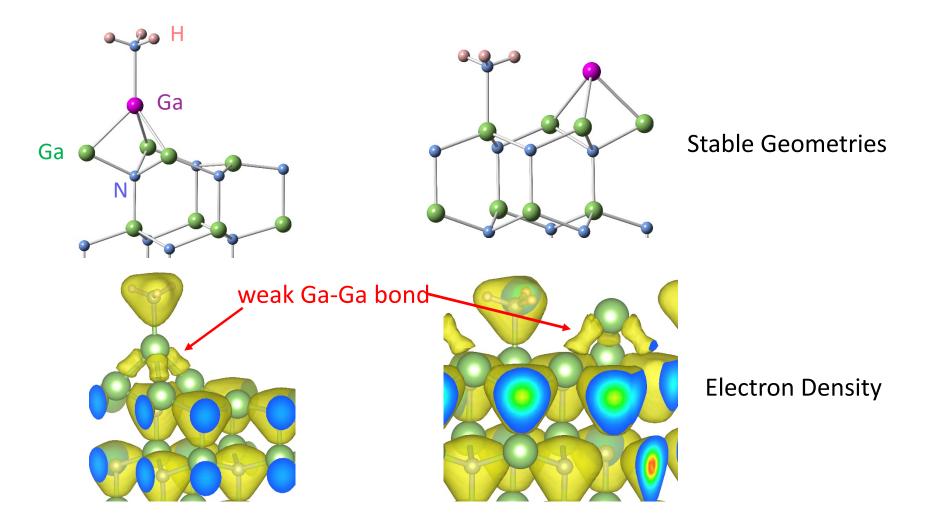
Decomposition of NH_3 is UNKOWN. But,,,High-ResolutionTOF measurements in Amano group show the existence of only NH_3 in the gas phase plus very small amount (0.1 %) of NH_2 .

Nagamatsu et al., Phys. Sttus Solidi B 254, 1600737 (2017)

Need to know:

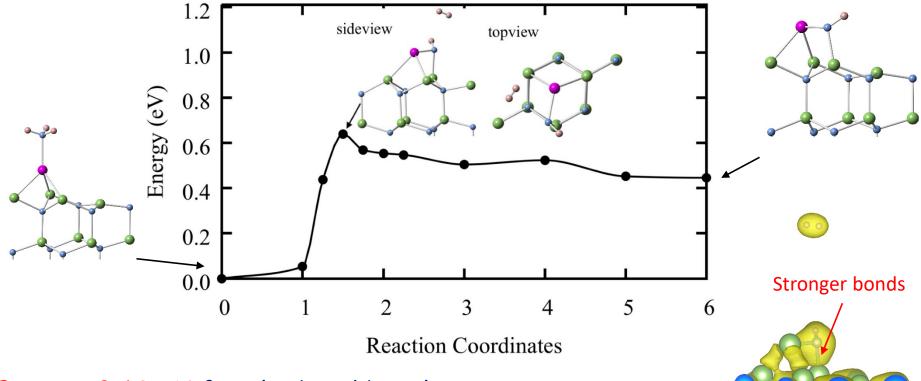
Behaviors of NH_3 and possible NH_x on the growing surface, which is Ga rich

NH₃ Adsorption on Ga-rich Surface



Ga dangling bond UNOCCUPIED: Electron Counting Rule

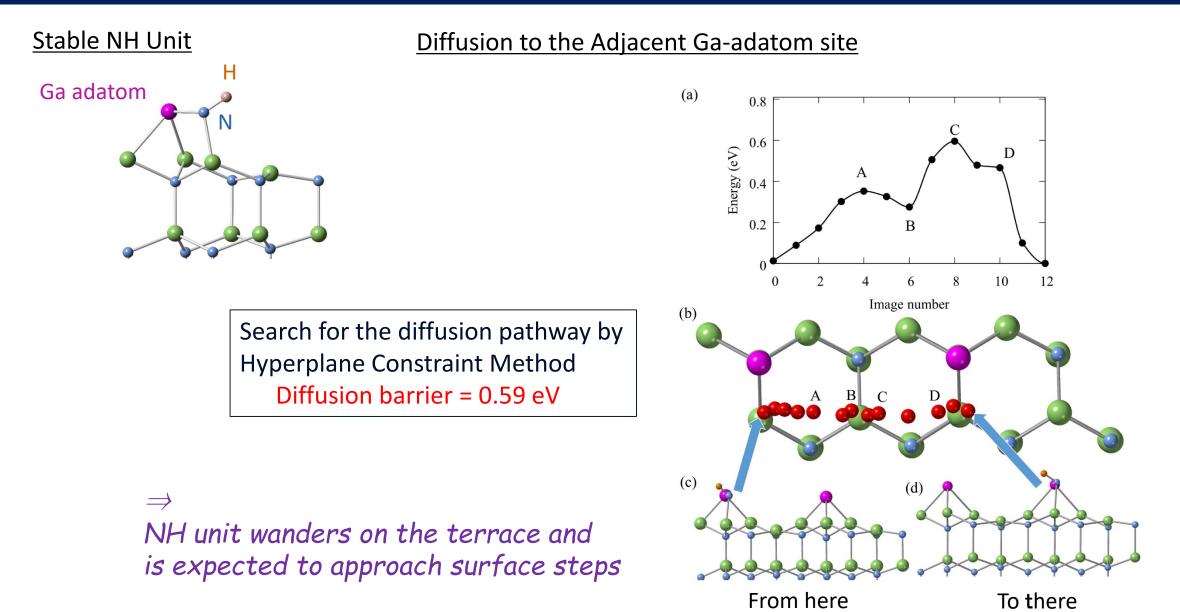
Decomposition of NH_3 ($NH_3 \rightarrow NH/GaN + H_2$)



- ✓ Small Barrier 0.63 eV for the bond breaking reaction
- ✓ Weak Ga-Ga bond is converted to two strong Ga-N bonds

✓ When we consider free-energy gain of H₂ in the gas phase, $\mu_{H2} = -k_BT \ln[gk_BT / p\varsigma_{trans}\varsigma_{rot}\varsigma_{vibr}] = -2.1 \text{ eV}$ under growth condition the reaction becomes exothermic

Diffusion of the NH unit on GaN(0001) Adatom Surface

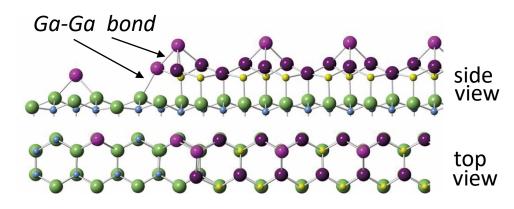


4

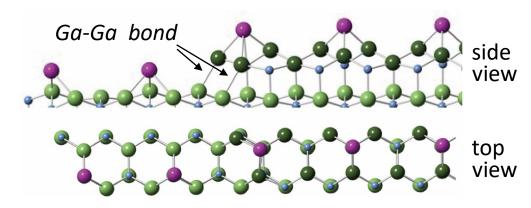
Electron Density at Step Edges: Ga-Ga Weak Bonds

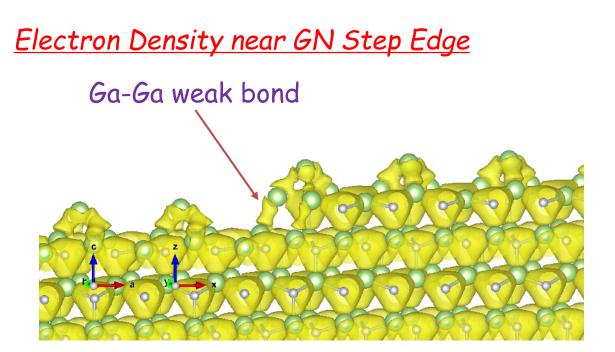
Ga Atoms near Step Edges]

GN Step



Ga2 Step

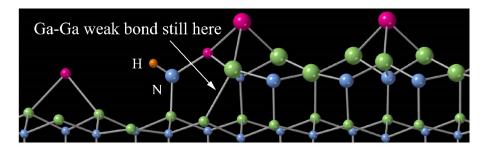


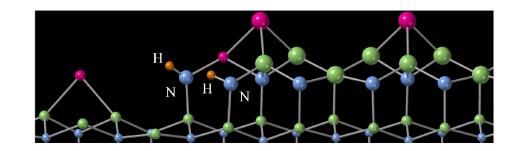


Ga-Ga weak bond: Hot spot for the growth

NH Incorporation at GN Step Edges,,, and then Step-Flow Growth

NH Intervening in Ga-Ga Weak Bonds at GN Step Edges





✓ 2 isolated NH in Ga-Ga bond on terrace -> 2 NH at step edge + 0.45 eV <u>Exothermic Attraction at Step Edges</u>

New Ga on Ga-rich Surface -> Incorporation of the new Ga with H2 Desorbed

